

Fig. 10(A) FORMATION OF PROTECTIVE INSULATION FILM

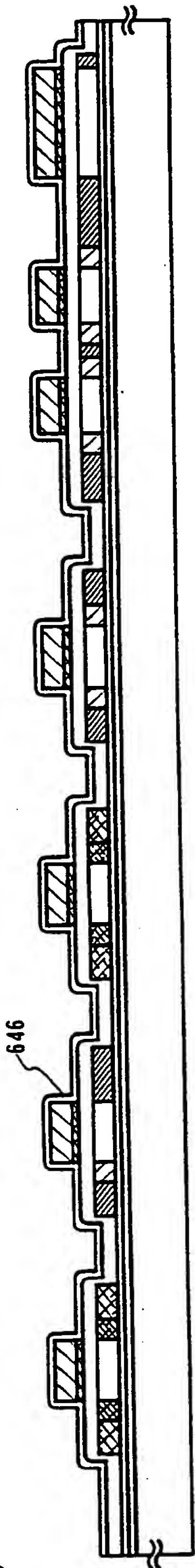


Fig. 10(B) ACTIVATION STEP

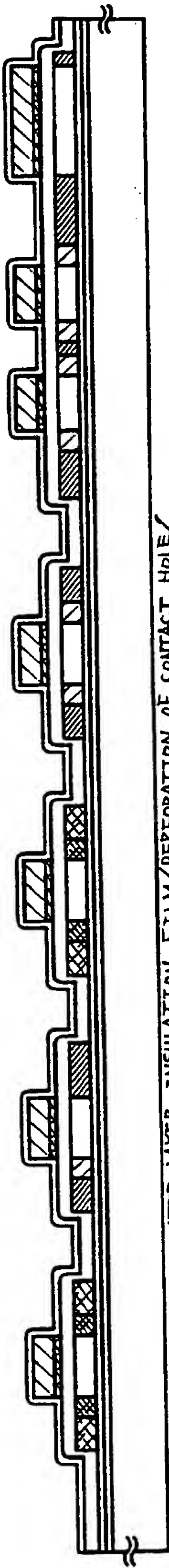
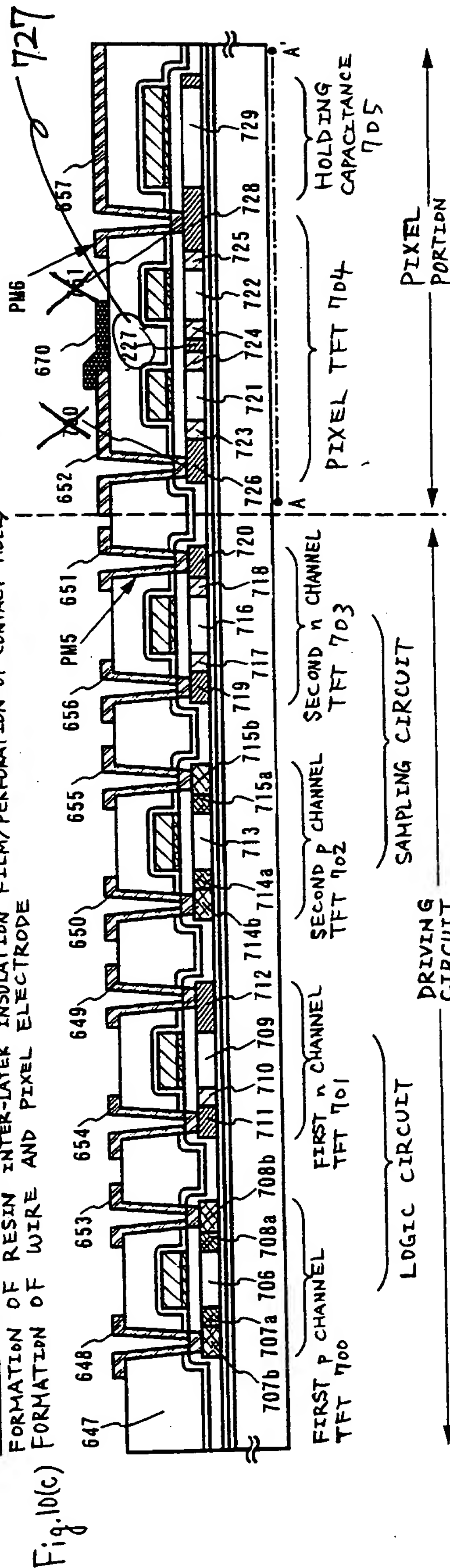


Fig. 10(c) FORMATION OF RESIN INTER-LAYER INSULATION FILM/PERFORATION OF CONTACT HOLE/  
FORMATION OF WIRE AND PIXEL ELECTRODE



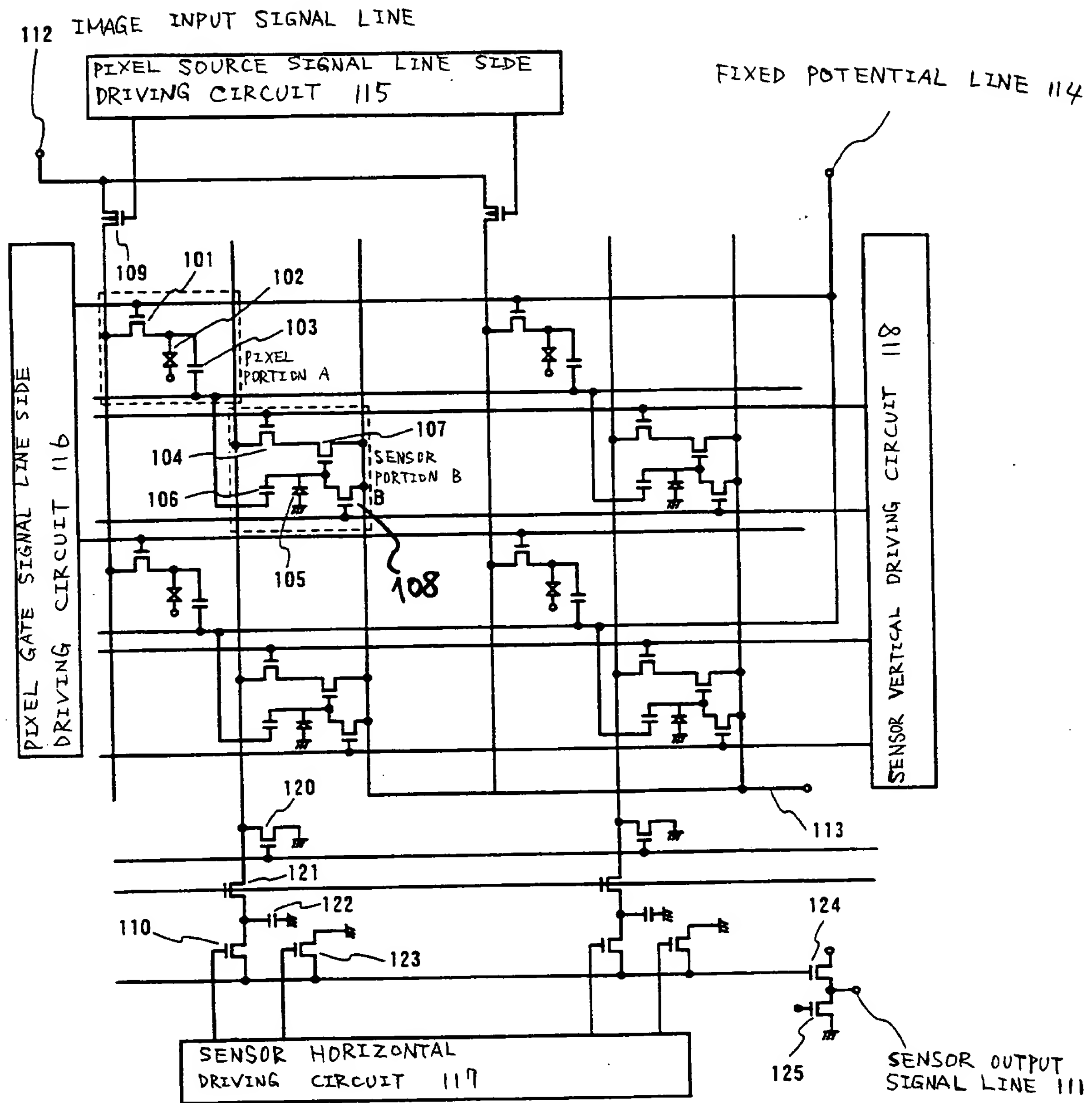


Fig. 14